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"Patterns and growth phenomena"

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Stochastic Model for Surface Erosion via Ion Sputtering: Dynamical Evolution from Ripple Morphology to Rough Morphology

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Surfaces eroded by ion sputtering are sometimes observed to develop morphologies which are either ripple (periodic) or rough (nonperiodic). We introduce a discrete stochastic model that allows us to interpret these experimental observations within a unified framework. We find that a periodic ripple morphology characterizes the initial stages of the evolution, whereas the surface displays self-affine scaling in the later time regime. Further, we argue that the stochastic continuum equation describing the surface height is a noisy version of the Kuramoto-Sivashinsky equation.

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A remarkable feature of erosion processes via ion sputtering in amorphous materials is the formation of a pattern consisting of a ripple structure, aligned in directions either parallel to or perpendicular to that of the bombarding beam of ions [1,2]. Indeed, we might expect that erosion tends to erase every possible feature of the surface morphology, and that the presence of noise in the system would further act against the formation of such a periodic pattern. Only recently have there been experimental [3] and theoretical [4] attempts to understand the formation of a ripple structure in the more general context of nonequilibrium interface growth phenomena [3]. Many such interfaces are "rough" and exhibit self-affine scaling at long distances and long times [1]; experimentally, one finds that surfaces eroded by ion bombardment also exhibit self-affine scaling behavior [5]. An outstanding question is then how to reconcile these observations with the formation of the periodic ripple structure.

In this Letter, we introduce a discrete stochastic model that incorporates the main physical mechanisms believed to influence the dynamics of the eroded surface morphology. We show that this model is characterized by an initial stage in which the surface morphology displays a ripple structure, and that subsequent stages are characterized by a crossover to a rough surface in the universality class of the Kardar-Parisi-Zhang (KPZ) equation [6]. We argue that the stochastic equation which provides the continuum description of our model is a *noisy* version [7] of the Kuramoto-Sivashinsky (KS) equation [8,9]. Thus we interpret the formation of a periodic pattern [3] and the development of rough interfaces [5] in the ion-sputtered systems as the early and late regimes, respectively, of the same dynamical process.

We first consider the main mechanisms [10] that determine the surface morphology undergoing ion bombardment.

(i) Erosion.—In ion sputtering, an initially flat substrate is bombarded with a well-collimated beam of heavy ions carrying a certain kinetic energy, and forming a pre-

cise angle with the normal to the uneroded surface. The phenomena leading to erosion take place within some finite distance from the surface. Namely, the ions penetrate inside the solid and induce along their path cascades of collisions among the atoms of the substrate. Atoms located at the surface may be affected by these collisions and acquire enough energy to leave the surface [11]. Consequently, atoms located at the bottom of troughs gain more energy on average and they are preferentially eroded as compared to those on the peaks of crests [12]. This "instability" can be thought of as a negative surface tension, since the surface tends to maximize its area.

(ii) Surface diffusion.—In physical systems there is a stabilizing mechanism that balances the negative surface tension, surface diffusion, which is always present at a nonzero temperature. Particles on the surface tend to diffuse looking for highly coordinated positions, a relevant phenomenon for sputtering [3,5] as well as for molecular-beam epitaxy (MBE) [13].

When the angle between the local normal to the surface and the incident beam approaches the grazing value, there is an increase in the reflection of the ions by the surface and the rate of erosion diminishes. This surface effect is beyond the approximations made in Sigmund's theory of ion sputtering [11], and is reflected in the angle

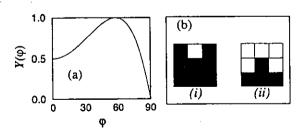


FIG. 1. (a) Sputtering yield $Y(\varphi)$ as a function of the angle φ . (b) Box rule for erosion. We define p_{ε} as the number of occupied neighboring sites (grey squares) inside the 3×3 box centered at site i (black square), normalized by 7. The examples shown correspond to (i) $p_{\varepsilon} = 1$ and (ii) $p_{\varepsilon} = 3/7$.

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dependence of the sputtering yield, $Y(\varphi)$, defined to be the number of eroded particles divided by the total number of bombarding ions. Here φ is the *local* angle of the ion trajectories to the surface normal at each point [14]. Typically [2], $Y(\varphi)$ is symmetric around $\varphi = 0$, presents a maximum between 60° and 80°, and decreases to zero as $\varphi \to 90^{\circ}$.

To define the model, we introduce two dynamical rules, one to account for erosion and one to account for surface diffusion. The rule for erosion incorporates the unstable behavior described above as well as the phenomenological dependence of the sputtering yield as a function of φ . The model for the case of 1+1 dimensions [15] is defined on a square lattice of lateral size L, with periodic boundary conditions in the horizontal direction. The initial interface is a horizontal line separating occupied sites (below) from empty sites (above). We choose randomly a site i at the interface where $i=1,\ldots,L$. The chosen site is subject to erosion with probability p, or to diffusion with probability 1-p, where the rules are as follows.

(i) Erosion (probability p).—[16] We compute $\varphi = \tan^{-1}[(h_{i+1} - h_{i-1})/2]$, where h_i is the height of the interface at site i, and apply the erosion rule with probability $Y(\varphi)$, as given in Fig. 1(a). To erode, we count the number of occupied neighbors inside a square box of size 3×3 lattice spacings centered in the chosen site i (box rule). We empty the site with an erosion probability p_e proportional to the number of occupied cells in the box [see Fig. 1(b)]. Thus the box rule favors the erosion of troughs as compared to the peaks of crests, and therefore is the source of the instability in the ion-sputtered system.

(ii) Surface diffusion (probability 1-p).—A diffusive move of the particle i to a nearest neighbor column is attempted with hopping probability $w_{i\rightarrow f}\equiv [1+\exp(\Delta\mathcal{H}_{i\rightarrow f}/k_BT)]^{-1}$, where $\Delta\mathcal{H}_{i\rightarrow f}$ is the energy difference between the final and initial states of the move. Following [17], we choose $\mathcal{H}\equiv (J/2)\sum_{\langle i,j\rangle}(h_i-h_j)^2$.

A continuum equation that describes the dynamics of the interface height has the form

$$\partial_t h(x,t) = \nu \nabla^2 h - \kappa \nabla^4 h + \eta(x,t) + f_Y[h(x,t)].$$

Here h(x,t) is the height of the interface at position x and time t, ν is a negative surface tension coefficient, κ is a positive coefficient that accounts for the surface diffusion, and $\eta(x,t)$ is a Gaussian noise term with short range correlations and strength 2D that accounts for the fluctuations in the flux of incoming particles. The functional $f_Y[h]$ takes into account the contribution of nonlinear terms, which appear in the equation of motion due to the effect of $Y(\varphi)$, itself a nonlinear function of the local slope $\nabla h \equiv \tan \varphi$. The nonlinearities become more relevant in the equation of motion at the late regime of the evolution when large slopes develop (see below).

First we study the model in the case $Y(\varphi) \equiv 1$, which approximately holds at the early stages of evolution. We focus on the time dependence of the total interface width $W(t) \equiv \langle L^{-1} \sum_{i=1}^{L} [h_i(t) - \overline{h(t)}]^2 \rangle^{1/2}$, where $\overline{h(t)} \equiv L^{-1} \sum_{i=1}^{L} h_i(t)$, and the brackets denote an average over realizations of the noise. The erosion rule alone—corresponding to p = 1, $Y(\varphi) \equiv 1$ —leads to $W(t) \sim t$, which can be attributed to ν in (1) being a negative number [18]. Moreover, by considering only the erosion rule, but defined with probability $1 - p_e$, we find that the interface has the scaling properties of the Edwards-Wilkinson (EW) equation [19] that is obtained from (1) with $\nu > 0$, $\kappa = 0$, and $f_Y[h] = 0$. We understand this result since one favors the erosion of

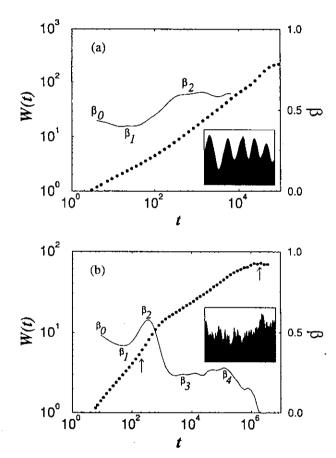


FIG. 2. Time evolution of the surface width for the cases $Y(\varphi) \equiv 1$ and L = 50. The solid line is the consecutive slope of the width, showing the value of the growth exponent β in each regime. The inset shows the ripple structure of the interface at t = 1000. The saturation observed in W(t) is due to the discreteness of the lattice: the erosion rule breaks down when the local slopes of the interface are bigger than 3 [20]. This effect can be avoided by using a bigger box. (b) Interface width as a function of time for the full model showing the regimes of the evolution for L = 2048. As in (a), the solid line is the consecutive slope. The inset shows a portion of the rough morphology at the late regime, where the self-affine scaling behavior holds. The arrows indicate the times at which the structure factor is displayed in Fig. 3.

peaks as compared to valleys, leading to the smoothing mechanism characteristic of a positive surface tension. On the other hand, the surface diffusion mechanism alone [for $p = 0, Y(\varphi) = 1$] is well described by (1) with $\nu = 0$, $\kappa > 0$, and $f_{\gamma}[h] = 0$, i.e., the linear MBE equation [13,17]. When mechanisms (i) and (ii) above are considered simultaneously for $J/k_BT = 5$, p = 0.5, and $Y(\varphi) \equiv 1$, we obtain the different stages of the time evolution displayed in Fig. 2(a) [21]. There exists a first region [22] for which $W(t) \sim t^{\beta_1}$, with $\beta_1 = 0.38 \pm 0.02$, the growth exponent for the linear MBE universality class, after which W(t) scales with $\beta_2 > 0.5$ due to the instability caused by $\nu < 0$. In this case, a linear stability analysis of (1) shows that there is a maximally unstable mode in the system, $k_m = (|\nu|/2\kappa)^{1/2}$, and therefore the surface is almost periodic [inset in Fig. 2(a)].

Next we consider the model with $Y(\varphi)$ shown in Fig. 1(a). The results are not expected to depend strongly on the specific form of $Y(\varphi)$, so long as it preserves the existence of a maximum, and $Y(0) \neq 0$, $Y(90^{\circ}) = 0$ [23]. Figure 3 shows the structure factor $S(k) \equiv \langle \hat{h}(k,t)\hat{h}(-k,t)\rangle$ at the onset of the instability. Here $\hat{h}(k,t)$ is the Fourier transform of $h_i(t) - \overline{h(t)}$. As we see, the early stages of the dynamics are still dominated by the periodic ripple structure defined by the competition between surface tension and surface diffusion, described by the linear part of (1).

For later times, the large slopes built up by the instability induce nonlinear effects, and the interface results in a rough morphology [inset of Fig. 2(b)]. In Fig. 2(b), we present the time evolution of W(t) for the complete model. We again observe a first regime [22] with $\beta_1 = 0.38 \pm 0.03$, followed by unstable erosion ($\beta_2 > 0.5$). For later stages, we find $\beta_3 = 0.23 \pm 0.03$, consistent with EW, after which a crossover to $\beta_4 = 0.28 \pm 0.03$ is found. Finally, the width saturates due to

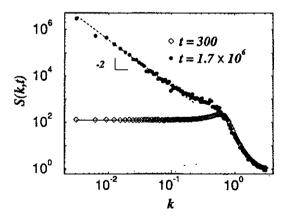


FIG. 3. Structure factor computed using the full model for a system with L=2048. For t=300, averaged over 2600 noise realizations (\diamond), and for $t=1.7\times10^6$, averaged over 39 realizations (\diamond) [see arrows in Fig. 2(b)]. The solid line is a fit by the exact solution of the discretized linear part of Eq. (1). The dashed straight line has slope -2.

the finite size of the system. Note that the value of the growth exponent for the KPZ equation is $\beta_{KPZ} = 1/3$ [6]. At saturation, S(k) displays the small momenta behavior $S(k,t) \sim k^{-2}$, consistent with the scaling of both the EW and KPZ universality classes (see Fig. 3). To determine if a KPZ nonlinearity is present in Eq. (1). we compute the mean velocity v(m) of the interface in the saturated regime as a function of an average tilt $m = \langle \nabla h \rangle$ imposed by using helical boundary conditions. If we assume that the relevant nonlinearity in (1) is of the KPZ type, then $f_Y[h] = (\lambda/2) (\nabla h)^2$. Taking spatial and noise averages in (1), $v = v_0 + (\lambda/2)m^2$, where v_0 is the velocity of the untilted interface [24]. The parabolic shape of v(m) obtained in our simulations (see Fig. 4) leads to the conclusion that the long time and long distance behavior of the model falls into the KPZ universality class. Moreover, the continuum equation describing the model ion-sputtered surfaces is the noisy KS equation

$$\partial_t h = \nu \nabla^2 h - \kappa \nabla^4 h + \frac{\lambda}{2} (\nabla h)^2 + \eta(x, t). \tag{2}$$

To compare the dynamics of (2) with those obtained for the discrete model, we integrate numerically Eq. (2) in 1 + 1 dimensions. Figure 5 shows the behavior of the function W(t). We observe the same crossovers as in the model [22]: $\beta_1 = 0.38 \pm 0.03$ corresponding to the linear MBE case, followed by unstable growth $\beta_2 > 0.5$. Then, a transition to EW behavior $\beta_3 = 0.25 \pm 0.03$ is observed, after which the nonlinearities dominate and a KPZ growth with $\beta_4 = 0.30 \pm 0.03$ is obtained. Finally, the interface width saturates due to the finite size of the system. Consistent with these numerical findings, the late scaling of Eq. (2) has been shown through a renormalization-group calculation [7] to be that of the KPZ equation in 1 + 1 and 2 + 1 dimensions. As we see, both in the model and the noisy KS, there is a long crossover time from EW to KPZ behavior, responsible for the difference between β_4 and β_{KPZ} , and for the narrow

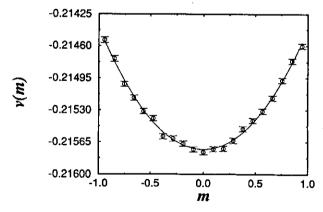


FIG. 4. Plot of the mean velocity v(m) as a function of the average tilt m of the interface, calculated in the saturated regime for L = 128, and averaged over 810 noise realizations. The solid line is a fit to a parabola.

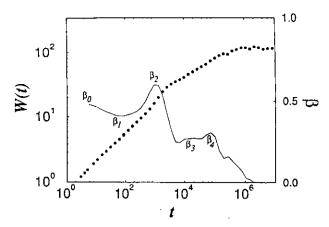


FIG. 5. Log-log plot of the interface width as a function of time obtained in the numerical integration of Eq. (2). The mesh is $\Delta x = 1.0$ and the time step $\Delta t = 0.005$. Parameter values are $\nu = -1$, $\kappa = 1$, $\lambda = 4$, D = 0.5, and L = 1024. The solid line gives the consecutive slopes.

window in which β_4 is observed—we find that the width of this window increases systematically with L. A similar phenomenon is well known to occur in the *deterministic* KS equation in 1 + 1 dimensions (see Sneppen *et al.* [9].

Finally, we compare the results of the model with observations of recent experiments [25]. The experimental development of a ripple structure [3] is well understood in terms of the unstable linear theory of ion sputtering describing the early stages of the time evolution of the model presented here. Moreover, the model predicts that in the late regime the large slopes generated by the unstable growth trigger the action of nonlinearities which stabilize the surface. The nonlinearity we find is of the KPZ type, consistent with the experimental observation of KPZ scaling reported by Eklund *et al.* [5]. To confirm the above picture, it would be of interest to study experimentally if both regimes do effectively take place in the time evolution of the *same* physical system.

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- [25] Based on our identification of Eq. (2) as describing the model, and the scaling of this equation in 2 + 1 dimensions predicted in [7], we expect our results to carry over for the physical case of two-dimensional surfaces. An important ingredient in 2 + 1 dimensions is the anisotropy between the two substrate directions induced by the ion beam. This leads to effects such as the change in the orientation of the ripples as a function of the angle of incidence [12], and could be accounted for by introducing a non-zero angle of incidence.

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> GRUPO INTERDISCIPLINAR DE SISTEMAS COMPLICADOS

Patterns and Growth Phenomena

Collaborators:

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ICTP, Trieste Hilda Cerdeira

What are patterns?

M.C. Cross, P.C. Hohenberg Rev. Mod. Phys. 65, 851 (1993)

Unified description based on linear instabilities of homogeneous sta Characteristic wavevector qo and frequency wo

· Is: W=0, qof0

III₀: W₀≠0, q₀=0

· Io: W+0, 90 +0

Relationship of patterns and spatio-temporal chaos

Low dimensional chass

. Order and disorder in spartial patherns

More on patterns:

Patterns: Formation and Competition

in "Lectures in the Sciences of Complexity", Addison-Wesley, 1990) (Excerpt from D. Campbell, "Introduction to Nonlinear Phenomena,

equilibrium, the many localized coherent structures that typically stable, others unstable, and the vast majority metastable. Highly anisotropic configurations must first be studied via experimental arise can <u>organize themselves into</u> a bewildering array of spatial yet one frequently observes patterns of coherent structures. (... A typical, extended, nonlinear nonequilibrium system will have many possible configurations or patterns; some of these will be patterns, reqular or random. Perhaps the most familiar example turbulent fluid flow, in which the temporal behavior is chaotic symmetric patterns may be accessible analytically, but general mathematics. (...) The interplay between coherent structures When a spatially extended nonlinear system is driven far from give rise to a myriad of patterns, which compete on a continuous basis. temporal chaos can typically form and Aim: Present (a few) examples of "pattern issues" arising from growth phenomena and models • Ion sputtering: • Periodic patterns vs chaos

Noisy Kuramoto-Sivashinsky equation

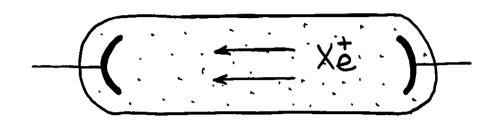
· Epitaxial growth: · Collective locking

Random patterns

· Noisy nonlinear diffusion equations

Ion sputtering:

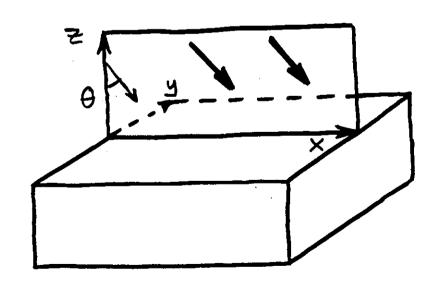
Old technique (~125 years!)



Many applications:

polishing, cleaning
thin film deposition
controlled removal

Experimental setup:



S: 02 I KeV Xe , 8~55°

Graphite
5 KeV At ,, 0 ~ 60°

Eklund et al.

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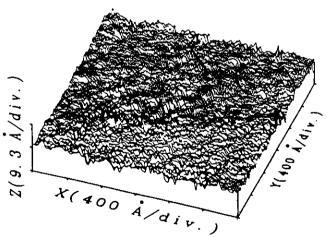


FIG. 1. Constant-current STM topograph of a graphite surface after sputtering with a flux J of 6.9×10^{13} ions/cm² sec and an ion fluence Q of 10^{16} ions/cm² at room temperature. The X and Y dimensions are 2400 Å and the total Z dimension is 18.6 Å.

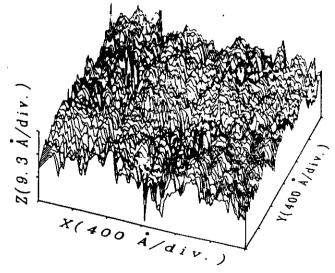
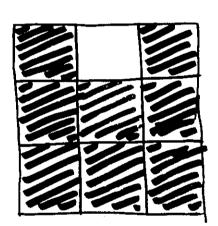


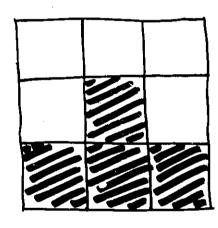
FIG. 2. STM topograph with the same parameters as that in Fig. 1, except that $Q = 10^{17}$ ions/cm² and the total Z scale is 27.9 Å.

Inicialmente:

2 reglas ~> (tasa relativa p)

i) Erosión (p):

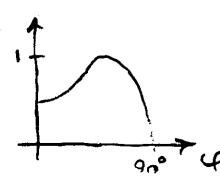


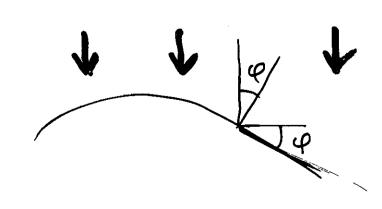


Inestabilidad

Efectividad

YLQ)





de la superficie (1-p)





Affirst = Affinar - Hinicial, $H = J\sum_{i=1}^{L} (h_i - h_{i+1})$ MBE Siegert y Plischne

El modelo evoluciona según

$$\frac{\partial h}{\partial t} = -121 \frac{\partial^2 h}{\partial x} + \frac{1}{2} \left(\frac{\partial^2 h}{\partial x} \right)^2 - \frac{1}{2} \frac{\partial^2 h}{\partial x} = -\frac{1}{2} \frac{\partial^2 h}{\partial x} + \frac{1}{2} \left(\frac{\partial^2 h}{\partial x} \right)^2 - \frac{1}{2} \frac{\partial^2 h}{\partial x} = -\frac{1}{2} \frac{\partial^2 h}{\partial x} + \frac{1}{2} \left(\frac{\partial^2 h}{\partial x} \right)^2 - \frac{1}{2} \frac{\partial^2 h}{\partial x} = -\frac{1}{2} \frac{\partial^2 h}{\partial x} + \frac{1}{2} \left(\frac{\partial^2 h}{\partial x} \right)^2 - \frac{1}{2} \frac{\partial^2 h}{\partial x} = -\frac{1}{2} \frac{\partial^2 h}{\partial x} + \frac{1}{2} \frac{\partial^2 h}{\partial x} + \frac{\partial^2$$

Kuranoto-Sivashinsky

evolución temporal:

estructura superficie Simple rugosa (inestabilidad) (KPZ)

Dynamic scaling (brief detour):

Rough surfaces are ubiquitous Characterisation:

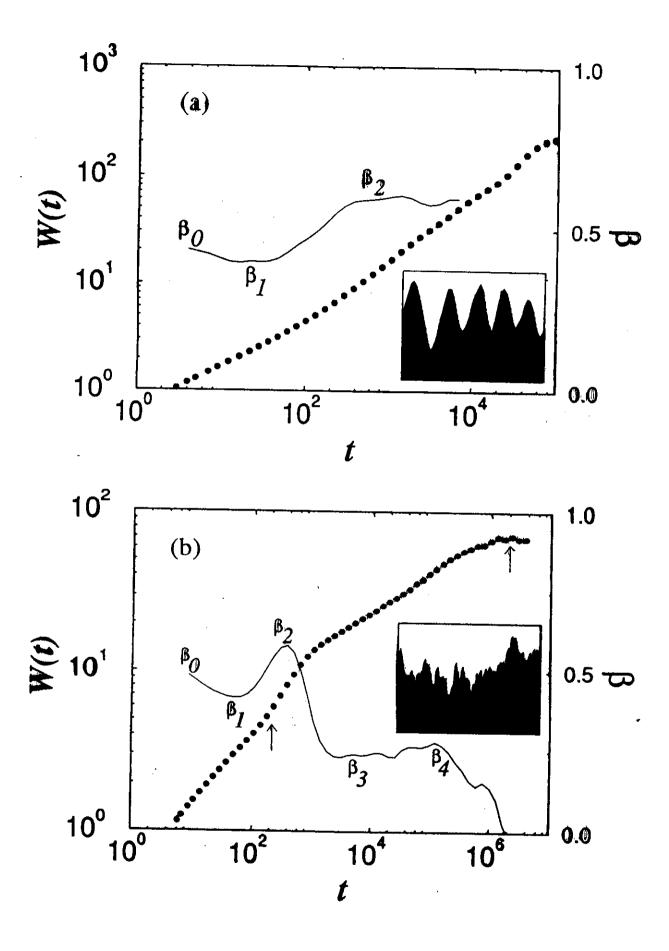
Mean height: THE + E Litt

WIDTH (rms): $\omega^2(L,t)=\left\langle \frac{1}{L}\sum_{i=1}^{L}\left(\text{Litt}-L(t)^2\right)\right\rangle$

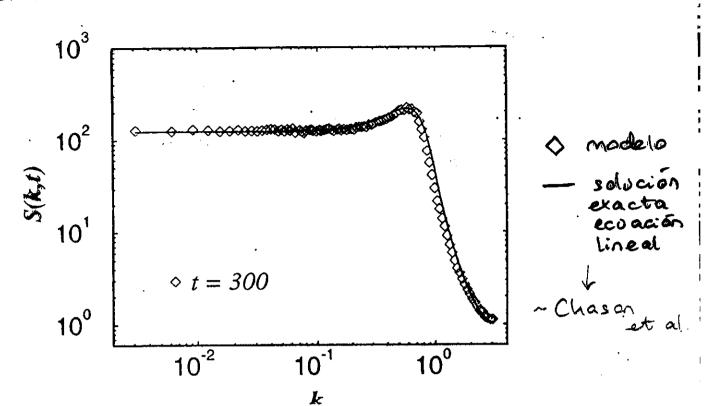
Observations:

ω(L,t)~t', t<<tx ω_{sa+}(L)~L", t>> tx

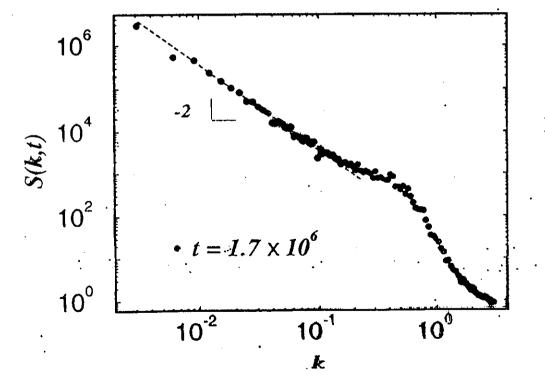
tx ~ L2



Inicialmente



Etapas tardias



consistente

con KPZ

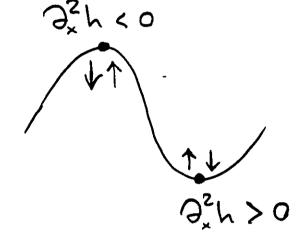
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at al.

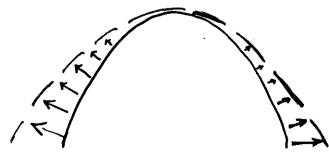
Thysical considerations:

$$\times \longrightarrow -\times$$
 NOT $y \longrightarrow -y$ O.K.

* Surface tension:



Lateral motion:
$$A_{t}h = \frac{\lambda}{2}(\lambda_{x}h)^{2}$$
Lateral motion



along normal Kardar, Parisi, Zhang

Additional physical mechanisms:

Curvature driven Thermally activated

$$\frac{\partial h}{\partial t} + \nabla \cdot \vec{j} = 0 \quad \text{if } \vec{j} = -\nabla \mu$$

μ~- - 2° h > 0

m ~ - corrature

$$\frac{\partial h}{\partial h} = - \times \Delta_{5}(\Delta_{5}h)$$

* Fluctuations in the beam:

$$\langle \gamma(2,t) \gamma(2',t') \rangle = 2D \delta(2-2') \delta(t-t')$$

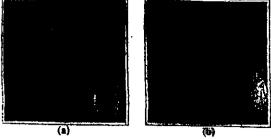


FIG. 2. Gray level plot of two snapshots of a system of size 50×50 with $\alpha = -1$ and isotropic nonlinearity ($\beta = 1$). The left picture was taken at an early time, before the nonlinearity becomes relevant (the amplitude still being small). The right shows the same system at a later time, in the chaotic regime. The ripples pinch off.

Rost, Krug PRL 1975

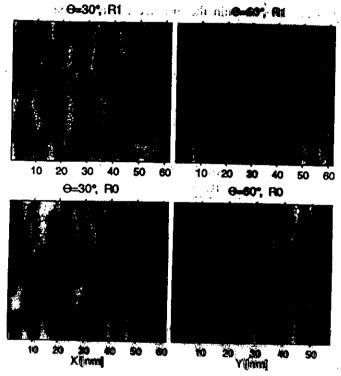


FIG. 4. The effect of diffusion on the ripple formation. The angle of incidence and the model of surface relaxation are denoted. The fluences corresponding to the situation shown are for model R1 approximately 2×10^{17} ions/cm² and for model R0 5 \times 10¹⁶ ions/cm². Otherwise similar to Fig. 1.

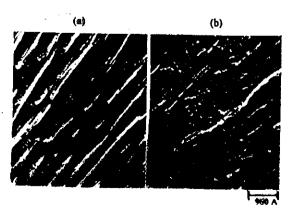
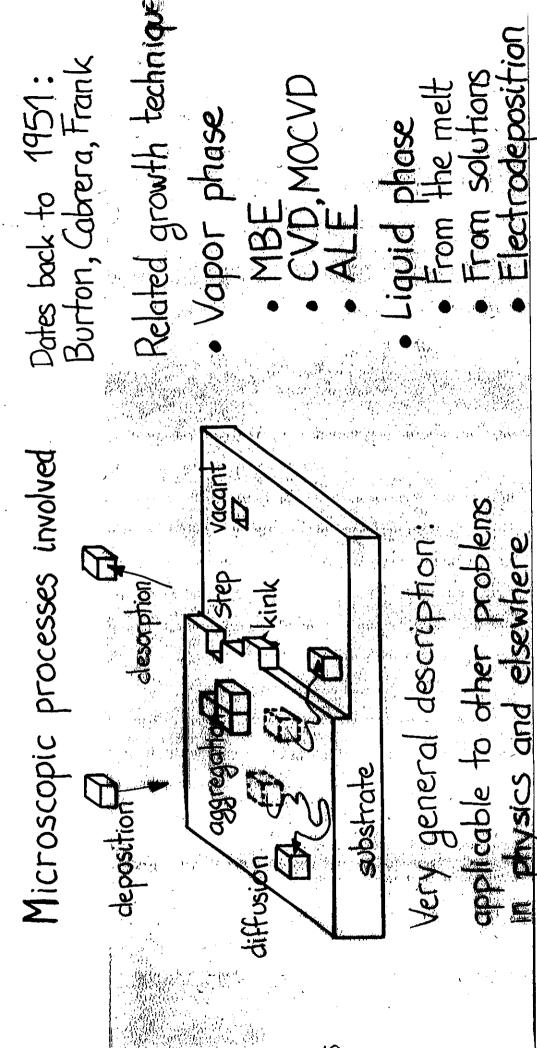


FIG. 4. Two images acquired at $T_0 = 200$ K after sputtering at equal fluence (10.5 ML) but at different ion fluxes, 0.035 ML sec⁻¹ (a) and 0.01 ML sec⁻¹ (b), respectively. $T_S = 300$ K and $E_i = 1$ keV.

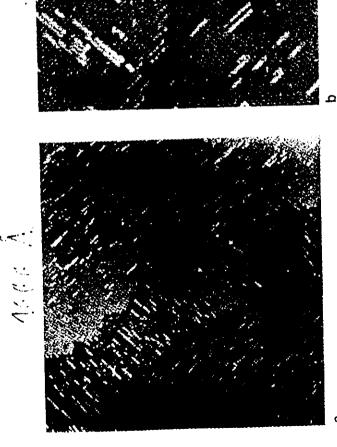
Koponen et al

Fostor et i.

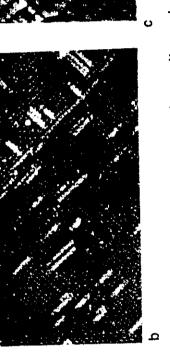


12/20/95 Cienat

Deposición de Si en fase gaseosa







surface, observed at various magnifications with a scanning tunneling microscope. In all the images, brighter regions are higher, a. At low magnification (with a field of Growth of two-dimensional silicon islands on a Si(001)

 Distintos regímenes de crecimiento . Distintos niveles de descripción

· Auto-afinidad

[M.G. Lagally, Phys. Today November 93 27]

zuer zubric#9**%e**n

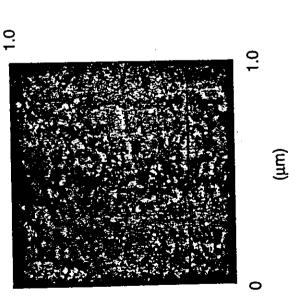


FIG. 1. Atomic force microscope images of GalnP layers grown on singular (001) GaAs substrates at 670 °C at growth rates of (a) 0.25 and (b) 2.0 µm/h. The solid lines are in the [110] direction.

<u>@</u>

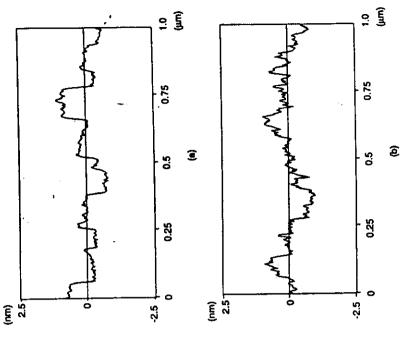
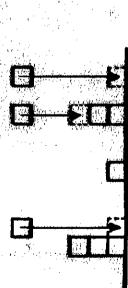


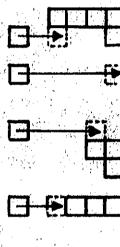
FIG. 2. Atomic-scale profiles of the surfaces of the GainP samples shown in Fig. 1; (a) 0.25, (b) 2.0 μ m/h taken along the solid lines in Fig. 1.

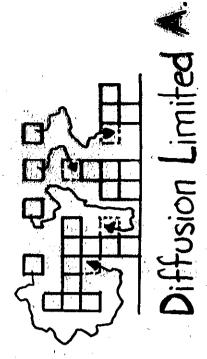
Chün, Lee, Ho & Stringfellow J Appl Phys 81, 646 (1997) Two Main Classes of Models:

•(Nonlinear) Stochastic PDEs eg KPZ EW

Discrete Models







Ballistic Dep. andom Vav.

A large family obeys Solid-On-Solid restriction Cellular Automata / Monte Carlo rules

Missiere Gaussian Model:

H=> (h;-h;+s)2

Adv. Chem. Phys. 40, 157 (1989) See: Weeks & Gilmer

La transición de "roughening"

192

J. D. WEEKS AND G. H. GILMER

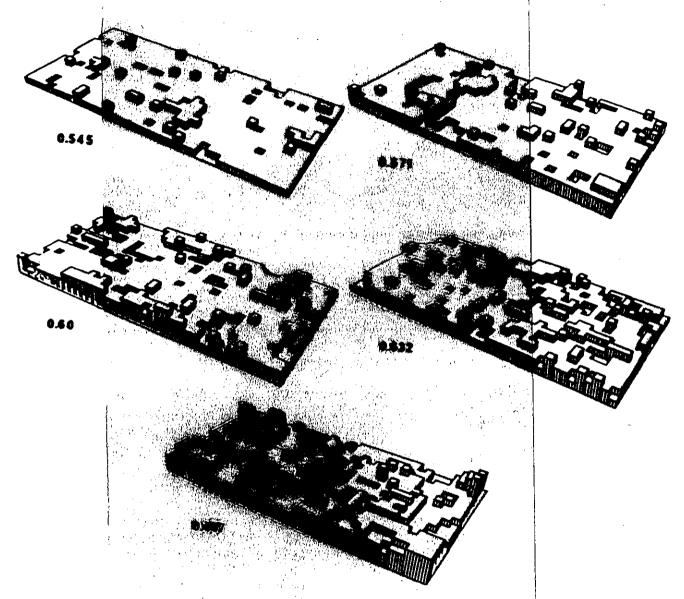


Fig. 10. Computer drawings of typical surfaces generated by the MC method at the indicated values of kT/\$\phi\$.

Simulación Monthe Carlo
(first prædicted the Burton, Cabrena, & Frank)
3D vs. Leaver By-Leaver growth

Equilibrium Roughening

Discrete Gaussian maps to Coulomb Gas:

Roughening in the Kosterlitz-Thouless class

Se Chair Weeks (M.

Property of

Caracterzation thru correlations

$$C(r) = \langle [R_{+r}] - L(R)]^2$$
 $C(r)$

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• Step creation energy vanishes at TR

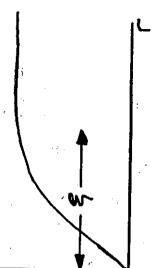
Related results

- Body Centered SOS exact van Beijeren, Phys. Rev. Lett. 38, 933 (1977)
 Rigorous about SOS

 Firelich & Spencer, Comm. Math. Phys. 81,

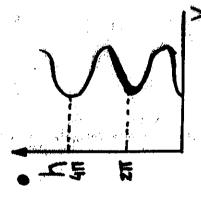
• Experimental evidence in several systems

527 (1981)



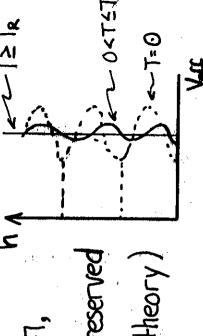
[Two-dimensional] Sine-Gordon model

sine-Gordon & (hi-hins)2-& cos hishie (discrete in space) Discrete Goussian Z (hi.-hi.s), hie Z is modified to



cos term favors h~2nF1,

roughening transition preserved (renormalization group theory)



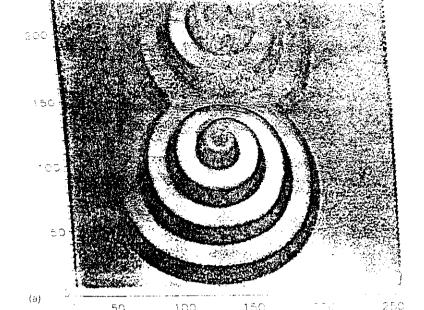
• Dissipative Dynamics

$$\dot{h}_{i} = \sum_{i} (h_{i} - h_{i,s}) + \sin h_{i} + I + \xi_{i}(1)$$

I: uverage vapor chemical potential / overcooling/saturation

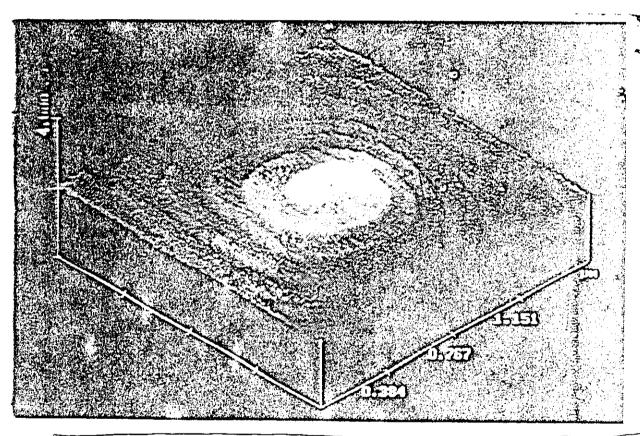
 ξ_i : Gaussian white noise, $\langle \xi_i \rangle = 0$, $\langle \xi_i \xi_j \rangle = 2 T \xi_{ij} \delta(t-t')$

Langevin molecular dynamics TR~25 at I=0 (equilibrium)



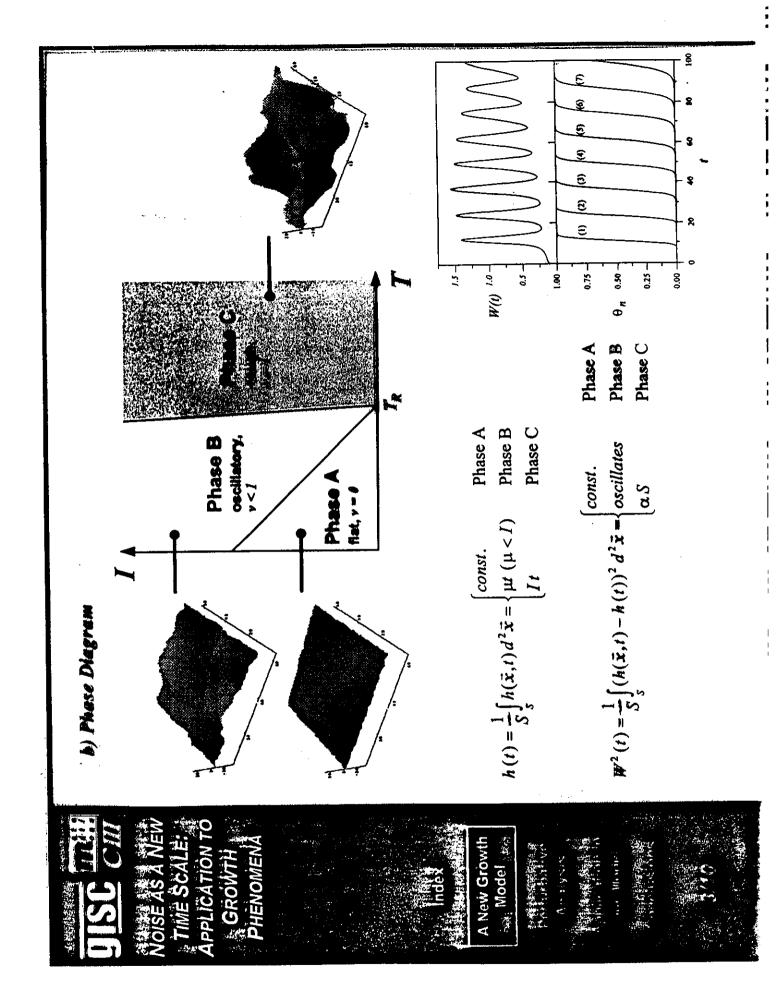
Model: Simulation (T20)

F. Falo, A. R. Bishop, P.S. Lomdahl, B. Horovitz (PRB 1991)



E2. AFM image (1.5 μ m×1.5 μ m) of GaAs growth spiral pattern. e width is around 150 nm and step height is 0.28 nm. Epitaxial layer erown on small area $(0.5 \text{ mm} \times 0.5 \text{ mm})$ mesas in the same growth run in the growth mechanism is a second to the growth mechanism in the growth mechanism is a second to the growth mechanism. ■ The growth mechanism is a second to the growth mechanism is a second to the growth mechanism. ■ The growth mechanism is a second to the growth mechanism is a second to the growth mechanism. ■ The growth mechanism is a second to the growth mechanism is a second to the growth mechanism. ■ The growth mechanism is a second to the growth mechanism is a second to the growth mechanism. ■ The growth mechanism is a second to the growth mechanism is a second to the growth mechanism. ■ The growth mechanism is a second to the growth mechanism is a second to the growth mechanism. ■ The growth mechanism is a second to the growth mechanism is a second to the growth mechanism. ■ The growth mechanism is a second to the growth mechanism is a exerent substrates under the same growth conditions.

C.C. Hsu, Y.C. Lu, J. B. Xu, I.H. Wilson (Appl. Phys. Lett. 1995)



m::: b) A

ISC CIII

VOISE AS A NEW TIME SCALE:

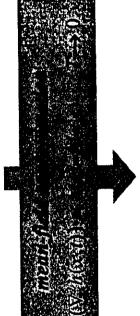
APPLICATION TO GROWTH Buendmend

Index | Index

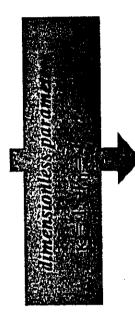
Perfurbative
Analysis
Application to

b) Approximations

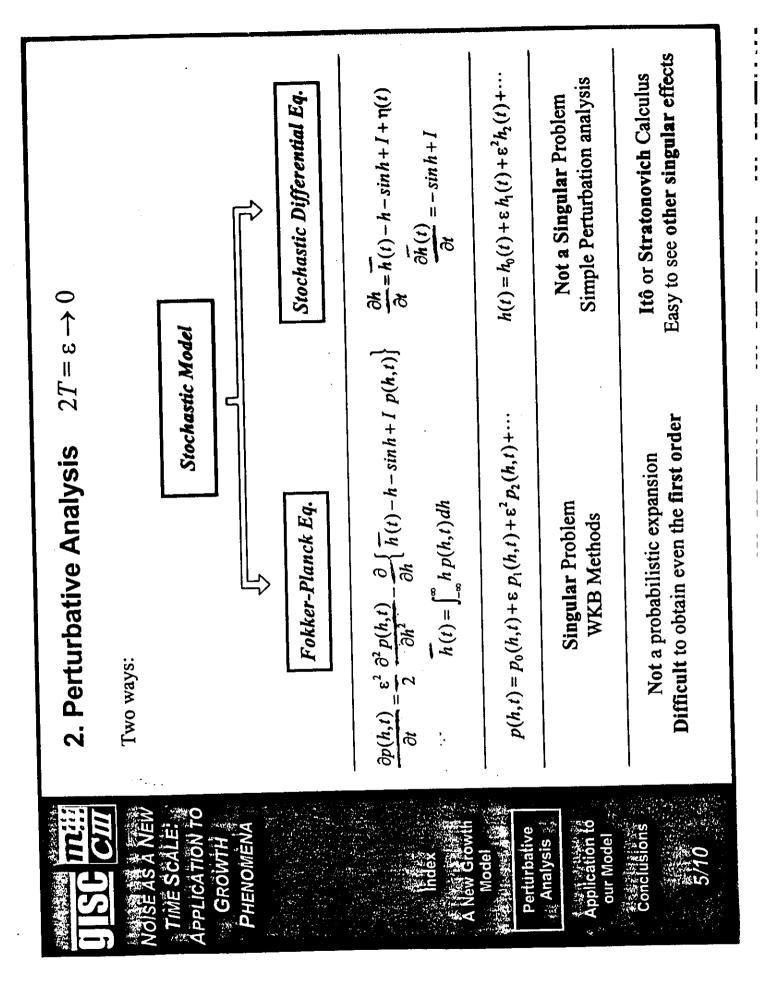
$\frac{\partial h(\vec{x},t)}{\partial t} = -\kappa \nabla^2 \left(\nabla^2 h(\vec{x},t) \right) - V_0 \sin 2\pi \frac{h(\vec{x},t)}{a} + I + \eta(\vec{x},t)$



$\frac{\partial h(\vec{x},t)}{\partial t} = \kappa \left[\overline{h}(t) - h(\vec{x},t) \right] - V_0 \sin 2\pi \frac{h(\vec{x},t)}{a} + I + \eta(\vec{x},t)$



$$\frac{\partial h(\vec{x},t)}{\partial t} = \overline{h}(t) - h(\vec{x},t) - \sinh(\vec{x},t) + I + \sqrt{2T} \, \xi(\vec{x},t)$$



UISC CIII NOISE AS A NEW TIME SCALE: APPLICATION TO GROWTH PHENOMENA

3. Application to our Model

- We will study the oscillations for I >> 1 (if $I = 1 + a\epsilon + O(\epsilon^2)$) the calculations more complicated)
- Inserting the ansatz in the mean field equation:

$$h(t) = h_0(t) + \varepsilon h_1(t) + \varepsilon^2 h_2(t) + \cdots$$

and equating coefficients of like powers of E:

$$O(0) \qquad \frac{\partial h_0}{\partial t} = \widetilde{h_0} - h_0 - \sin h_0 + I$$

$$O(\varepsilon) \qquad \frac{\partial h_1}{\partial t} = \overline{h_1} - h_1 - h_1 \cos h_0 + \eta(t)$$

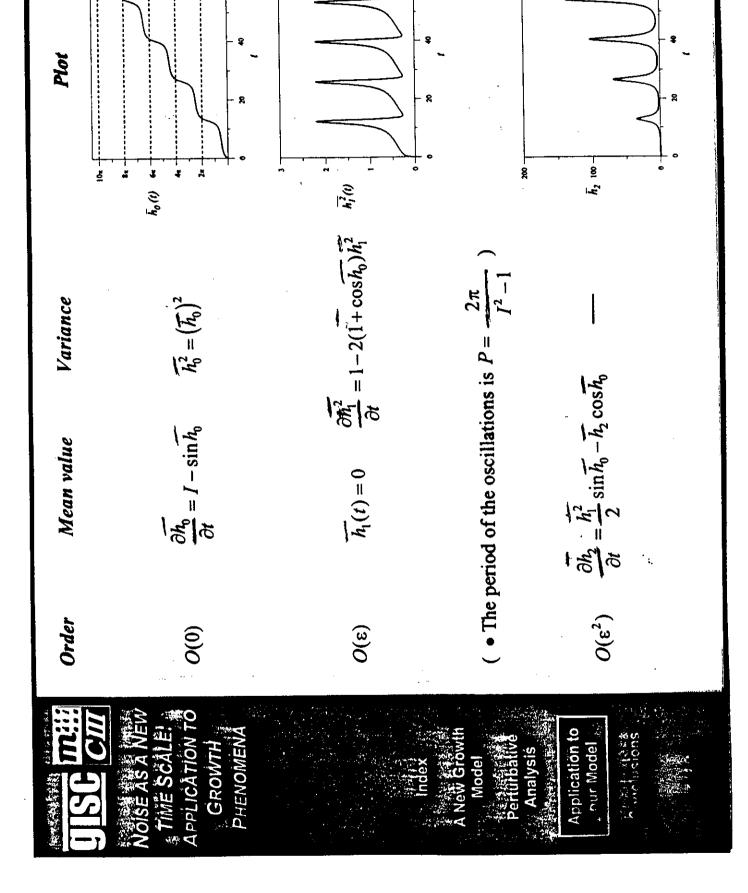
$$O(\varepsilon^2) \qquad \frac{\partial h_2}{\partial t} = h_2 - h_2 - h_2 \cosh_0 - \frac{h_1^2}{2} \sinh_0$$

• We are interested in the mean value and roughness:

Applichtion to our Model

$$h(t) = h_0 + \varepsilon h_1 + \varepsilon^2 h_1 + \cdots$$

$$W^2(t) = \varepsilon^2 h_1^2 + \cdots$$



• Our ansatz does not work because we need to take into account another time scale:

$$\frac{\partial h}{\partial t} = a(h,t) + \varepsilon \eta(t)$$

$$\frac{\partial h}{\partial t} = a(h,t) + \varepsilon \eta(t)$$
time scale $t = \varepsilon't$

$$\frac{\partial h}{\partial t} = a(h,t) + \varepsilon \eta(t)$$

Then the noise provides another time scale.

• We apply Lindstedt's method to deal with t and τ

$$t^* = t(1 + \alpha \varepsilon^2 + O(\varepsilon^3)) \Rightarrow$$

$$\frac{\partial h_0}{\partial t^*} = I - \sin h_0$$

$$\frac{\partial h_1^2}{\partial t^*} = 1 - 2(1 + \cos h_0) h_1^2$$

$$\frac{\partial h_2}{\partial t^*} = \left(\frac{h_1^2}{2} + \alpha\right) \sin h_0 - \alpha I - h_2 \cos h_0$$

ullet To calculate α we apply the solvability condition to the third equation

if
$$y(t^*)$$
 is solution of $Ly(t^*) = 0$, where $Ly = \frac{\partial y}{\partial t} + y \cosh_0 \Rightarrow y Lg$

$$g(t^*) = sinh_0 \left(\frac{h^2}{2} + \alpha \right) - \alpha I$$

Application to

TIME SCALE PHENOMENA

$$\alpha = \frac{1}{P} \int_0^{P} \frac{h_1^2}{2} \frac{\sin h_0}{I - \sin h_0} dt$$

$$P = \frac{2\pi}{2}$$

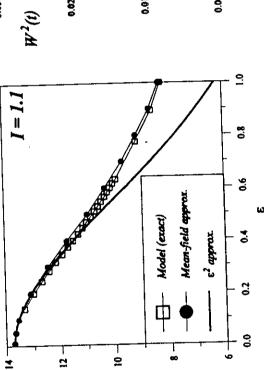
$$P^{\bullet} = \frac{2\pi}{r^2}$$

In the former time scale t, the period of the oscillations is equal to:

$$P = \frac{P}{1+\alpha(I)\varepsilon^2 + O(\varepsilon^3)} = \frac{2\pi}{I^2 - 1} \frac{1}{1+\alpha(I)\varepsilon^2 + O(\varepsilon^3)}$$

The period of the oscillations depends on the (E) temperature!!!

Comparison with numerical simulations



Application to

our model

Suoisions

